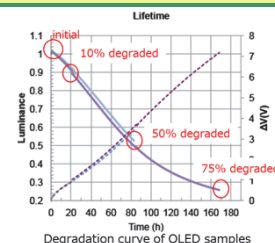
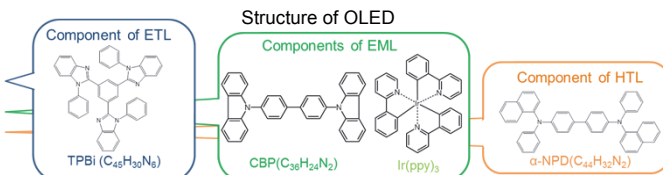
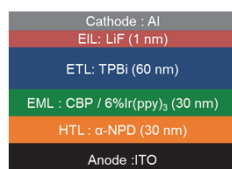


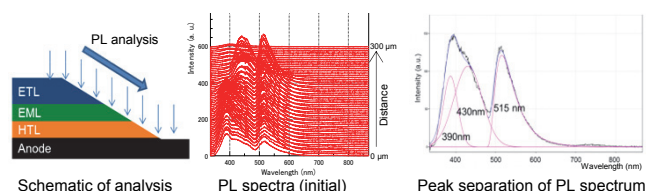
TOF-SIMS MS/MS for analysis of degradation product in OLED driving test

PL line analysis, GCIB-TOF-SIMS, and TOF-SIMS MS/MS were applied to the degradation analysis of OLED in driving test. TOF-SIMS MS/MS revealed the detailed chemical structure of degradation product in the specific depth region in OLED stacks.

■ test pattern size: 2 mmφ ■ driving test: initial, 10%, 50%, and 75% degraded

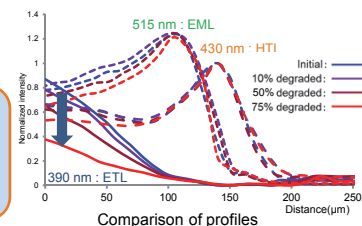


PL analysis of inclined surface

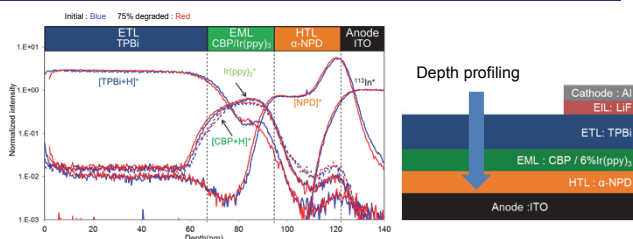


Comparison of profiles of PL intensities

Decrease of peak intensities in ETL
⇒ Degradation of ETL components

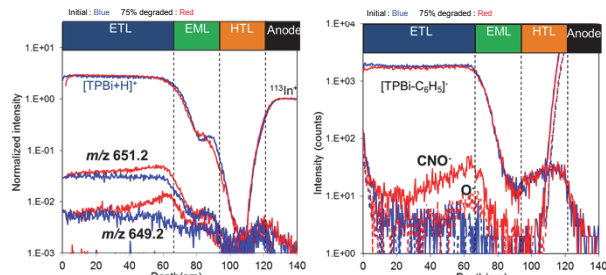


GCIB-TOF-SIMS depth profile of OLED



Intensities of main components and dopant were not changed after degradation.

Difference between the spectra of each layer ⇒ Depth profile

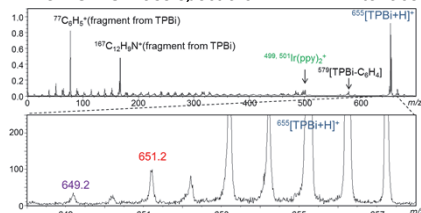


Degradation at EML ~ EML/ETL interface
⇒ Corresponding with PL results, m/z 649, 651 peaks were obtained from degradation products

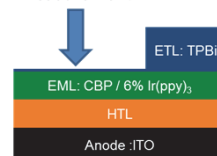
TOF-SIMS MS/MS

Ar-GCIB etching to ETL/EML interface ⇒ TOF-SIMS analysis

■ TOF-SIMS mass spectra of ETL/EML interface

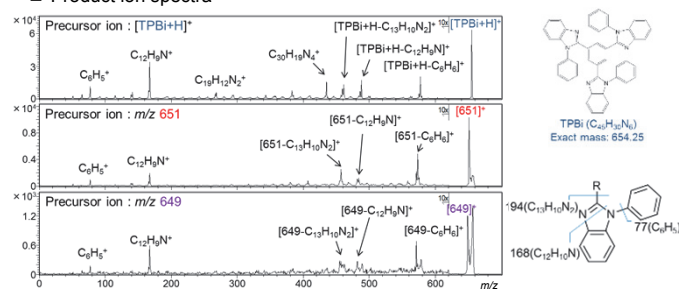


Measurement



Insufficient information in MS spectra ⇒ MS/MS analysis

■ Product ion spectra

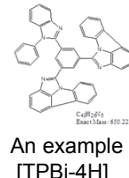
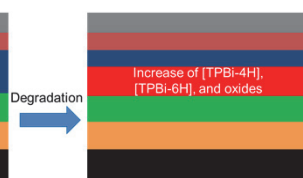
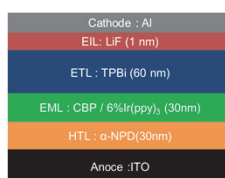


Degradation products can be assigned as derivatives of TPBi, [TPBi-4H] and [TPBi-6H].

Peaks in low m/z were common.
Shifts of peaks in high m/z were common.

⇒ Cyclization of TPBi

Summary



PL line analysis, GCIB-TOF-SIMS, and TOF-SIMS MS/MS were applied to OLED degradation analysis. These techniques revealed the detailed chemical structure of the degradation product in the specific depth region in OLED stacks.